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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/675,862	09/30/2003	Chao-Yuan Su	TSM03-0150	1880
43859	7590	07/01/2005	EXAMINER	
SLATER & MATSIL, L.L.P. 17950 PRESTON ROAD, SUITE 1000 DALLAS, TX 75252			TOLEDO, FERNANDO L	
			ART UNIT	PAPER NUMBER

2823

DATE MAILED: 07/01/2005

Please find below and/or attached an Office communication concerning this application or proceeding.

Office Action Summary

Application No.

10/675,862

Applicant(s)

SU ET AL.

Examiner

Fernando L. Toledo

Art Unit

2823

-- The MAILING DATE of this communication appears on the cover sheet with the correspondence address --
Period for Reply

A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) FROM THE MAILING DATE OF THIS COMMUNICATION.

- Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication.
- If the period for reply specified above is less than thirty (30) days, a reply within the statutory minimum of thirty (30) days will be considered timely.
- If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication.
- Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).

Status

- 1) ☒ Responsive to communication(s) filed on 08 April 2005.
- 2a) ☐ This action is **FINAL**. 2b) ☒ This action is non-final.
- 3) ☐ Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under *Ex parte Quayle*, 1935 C.D. 11, 453 O.G. 213.

Disposition of Claims

- 4) ☒ Claim(s) 1-64 is/are pending in the application.
- 4a) Of the above claim(s) 47-64 is/are withdrawn from consideration.
- 5) ☐ Claim(s) _____ is/are allowed.
- 6) ☒ Claim(s) 1-46 is/are rejected.
- 7) ☐ Claim(s) _____ is/are objected to.
- 8) ☐ Claim(s) _____ are subject to restriction and/or election requirement.

Application Papers

- 9) ☐ The specification is objected to by the Examiner.
- 10) ☐ The drawing(s) filed on _____ is/are: a) ☐ accepted or b) ☐ objected to by the Examiner.
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).
Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).
- 11) ☐ The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.

Priority under 35 U.S.C. § 119

- 12) ☐ Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).
- a) ☐ All b) ☐ Some * c) ☐ None of:
- ☐ Certified copies of the priority documents have been received.
 - ☐ Certified copies of the priority documents have been received in Application No. _____.
 - ☐ Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).

* See the attached detailed Office action for a list of the certified copies not received.

Attachment(s)

- 1) ☐ Notice of References Cited (PTO-892)
- 2) ☐ Notice of Draftsperson's Patent Drawing Review (PTO-948)
- 3) ☒ Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08)
Paper No(s)/Mail Date 20031223.
- 4) ☐ Interview Summary (PTO-413)
Paper No(s)/Mail Date. _____.
- 5) ☐ Notice of Informal Patent Application (PTO-152)
- 6) ☐ Other: _____.

DETAILED ACTION

Election/Restrictions

1. Applicant's election of claims 1 – 46 in the reply filed on 8 April 2005 is acknowledged. Because applicant did not distinctly and specifically point out the supposed errors in the restriction requirement, the election has been treated as an election without traverse (MPEP § 818.03(a)).
2. Claims 47 – 64 are withdrawn from further consideration pursuant to 37 CFR 1.142(b) as being drawn to a nonelected invention, there being no allowable generic or linking claim. Election was made **without** traverse in the reply filed on 8 April 2005.

Claim Objections

3. Claim 5 is objected to because of the following informalities: Claim 5 has the following limitation "wherein the low-k dielectric layer is a material selected from the group consisting of CVD..." CVD is a deposition technique and not a material per se. Appropriate correction is required.

Claim Rejections - 35 USC § 102

4. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless –

(b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

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5. Claims 1 – 46 are rejected under 35 U.S.C. 102(b) as being anticipated by Hara et al. (U. S. Patent 5,371,411 A).

6. In re claim 1, Hara, in the U. S. Patent 5,371,411 A; figures 1 – 13D discloses a first scribe line having a selected width extending along a first direction and adjacent a first die of the multiplicity of dies (Figure 4); a second scribe line having a selected width extending along a second direction adjacent the first die and intersecting the first scribe line at a corner point of the first die; at least one free area defined on at least one of the first and second scribe lines where placement of a test key is restricted (Figures 13A – 13D).

7. In re claim 2, Hara discloses wherein at least one layer of the wafer structure is a low-k dielectric layer (Column 4, Lines 27 – 31).

8. In re claim 3, Hara discloses wherein the low-k dielectric layer has a dielectric constant of less than approximately 3.5 (Column 4, Lines 27 – 31).

9. In re claim 4, Hara discloses wherein the low-k dielectric layer has a dielectric constant of less than 3.0 (Column 4, Lines 27 – 31).

10. In re claim 5, Hara discloses wherein the low-k dielectric layer is a material selected from the group consisting of CVD, SiOC, SiOCN, SiOC, CVD polymer, spin-on polymer, FSG, SiO₂ and combinations thereof (Column 4, Lines 27 – 31).

11. In re claim 6, Hara discloses wherein the free area is a free are A₁ on the first scribe line and is defined by the equation $A_1 = D_1 \times S_1$ where D₁ is the distance along the first direction extending from the corner point of the die, and S₁ is the width of the first scribe line (Figures 13A – 13D).

12. In re claim 7, Hara discloses wherein the free area is defined on the top of the multi-layer structure (Figure 4).

13. In re claim 8, Hara discloses wherein the free area is defined on at least one of the top three layers of the multi-layer structure (Figures 4 and 9).

14. In re claim 9, Hara discloses at least one test key formed in the free area, the at least one test key having a measurement ration R_1 , wherein the measurement ratio is defined by the equation $R_1 = M_1/A_1$, wherein M_1 is the total area of the at least one test key formed on the free area A_1 and R_1 is less than about 10% (Figures 13A – 13D).

15. In re claim 10, Hara discloses wherein the distance D_1 is less than about 600 μm (Figure 13A – 13D).

16. In re claim 11, Hara discloses wherein the width S_1 of the first scribe line is greater than about 20 μm (Figure 13A – 13D).

17. In re claim 12, Hara discloses wherein the multi-layer structure is formed on a substrate selected from the group consisting of bulk Si, SOI, SiGe, GaAs, InP, and a combination thereof (Column 3, Lines 46 – 49).

18. In re claim 13, Hara discloses wherein the die includes: a first peripheral region inside on an extending parallel to the first scribe line 13; a second peripheral region inside of an extending parallel to the second scribe line 13 and intersecting the first peripheral region to form a corner area 4; a conductive ring 12 formed between the die and the first peripheral region and the second peripheral region; and an array of apertures formed in the conductive ring and adjacent the corner area of the die (Figure 4).

19. In re claim 14, Hara discloses wherein the array of apertures includes at least two slots (Figure 13A – 13D).

20. In re claim 15, Hara discloses wherein the array of apertures includes two rows of holes (Figures 13A – 13D).

21. In re claim 16, Hara discloses wherein the array of apertures extends along at least one of the first peripheral regions and the second peripheral region (Figure 13A – 13D).

22. In re claim 17, Hara discloses wherein the die further includes a circuit area with several circuit elements, wherein the conductive ring is electrically connected to the circuit elements to apply one of a power source and a ground potential to the circuit elements (Figure 4).

23. In re claim 18, Hara discloses wherein the conductive ring has a width of between 50 μm and about 300 μm (Figure 11).

24. In re claim 19, Hara discloses wherein the free area is a free area A_s at the intersection of the first scribe line and the second scribe line and is defined by the equation $A_s = S_1 \times S_2$, wherein S_1 is the width of the first scribe line and S_2 is the width of the second scribe line (Figure 13A – 13B).

25. In re claim 20, Hara discloses further including at least one test key formed on the free area A_s , the test key having a measurement ratio R_s that is less than 10% and is defined by the equation $R_s = M_s / A_s$, wherein M_s is the total area of the at least one test key formed on the free area A_s (Figure 13A – 13B).

26. In re claim 21, Hara discloses wherein the width of the scribe line S_1 and S_2 is greater than about 20 μm (Figure 13A – 13D).

27. In re claim 22, Hara discloses wherein the at least one free area includes a first free area A_1 on the first scribe line and a second free area A_2 on the second scribe line, the first free area defined by the equation $A_1 = D_1 \times S_1$ where D_1 is the distance along the first direction extending from the corner point of the die and S_1 is the width of the first scribe line, the second free area defined by the equation $A_2 = D_2 \times S_2$ where D_2 is the distance along the second direction extending from the corner of the point of the die and S_2 is the width of the second scribe line (Figure 13A – 13D).

28. In re claim 23, Hara discloses including a third free area A_s at the intersection of the first scribe line and the second scribe line is defined by the equation $A_s = S_1 \times S_2$ (Figure 13A – 13D).

29. In re claim 24, Hara discloses at least one test key formed on at least one of the free areas A_1 , A_2 and A_s ; wherein a first measurement ratio R_1 is defined as the equation $R_1 = M_1 / A_1$, wherein M_1 is the total area of the test keys formed on the first free area A_1 ; wherein the second measurement ratio R_2 is defined as the equation $R_2 = M_2 / A_2$, wherein M_2 is the total area of the test keys formed on the second free area A_2 ; wherein the third measurement ratio R_s is defined as the equation $R_s = M_s / A_s$, wherein M_s is the total area of the test keys formed on the second free area A_s ; and wherein the total measurement ratio R is defined as the equation $R = (M_1 + M_2 + M_s) / (A_1 + A_2 + A_s)$ (Figures 13A – 13D).

30. In re claim 25, Hara discloses wherein R_1 is less than about 10% (Figures 13A – 13D).

31. In re claim 26, Hara discloses wherein R_2 is less than about 10% (Figure 13A – 13D).

32. In re claim 27, Hara discloses wherein R_s is less than about 10% (Figure 13A – 13D).

33. In re claim 28, Hara discloses wherein the R is less than about 10% (Figure 13A – 13D).

34. In re claim 29, Hara discloses wherein the first distance D_1 is less than about 600 μm (Figures 13A – 13D).

35. In re claim 30, Hara discloses wherein the second distance D_2 is less than about 600 μm (Figures 13A – 13D).

36. In re claim 31, Hara discloses wherein the width S_1 of the first scribe is greater than about 20 μm (Figures 13A – 13D).

37. In re claim 32, Hara discloses wherein the width S_2 of the second scribe line is greater than about 20 μm (Figures 13A – 13D).

38. In re claim 33, Hara discloses a first scribe line having a selected width extending along a first direction; a second scribe line having a selected width extending along a second direction and intersecting said first scribe line; four dies located at and separated by the intersection of said first and second scribe lines wherein each of the four dies comprises a corner point adjacent the intersection of said first and second scribe lines (Figure 4); a first free area A_1 on the first scribe line adjacent the corner point of the first die, wherein A_1 is defined by the equation $A_1 = D_1 \times S_1$ and wherein D_1 is the distance extending from the corner point of the first die, and S_1 is the width of the first scribe line; a second free area A_2 on the second scribe line adjacent the corner point of the second die, wherein A_2 is defined by the equation $A_2 = D_2 \times S_2$, and wherein D_2 is the distance from the corner point of the second die, and S_2 is the width of the second scribe line; a third free area A_3 on the second scribe line adjacent the third corner point of the third die, wherein A_3 is defined by the equation $A_3 = D_3 \times S_2$, and wherein D_3 is the distance from the corner point of the third die; a fourth free area A_4 on the first scribe line adjacent the corner point of the fourth die, wherein A_4 is defined by the equation $A_4 = D_4 \times S_1$, and wherein D_4 is the distance from the

corner point of the fourth die; and a fifth free area A_s on the intersection of the first scribe line and the second scribe line and is defined by the equation $A_s = S_1 \times S_2$ (Figures 13A – 13D).

39. In re claim 34, Hara discloses further including at least one test key formed on at least one of the free areas A_1 , A_2 , A_3 , A_4 and A_s ; wherein a first measurement ratio R_1 is determined as the equation $R_1 = M_1 / A_1$, wherein M_1 is the total area of the test keys formed on the first free area A_1 ; wherein a second measurement ratio R_2 is defined as the equation: $R_2 = M_2 / A_2$, wherein M_2 is the total area of the test keys formed on the second free area A_2 ; wherein a third measurement ratio R_3 is defined as the equation: $R_3 = M_3 / A_3$, wherein M_3 is the total area of the test keys formed on the third free area A_3 ; wherein a fourth measurement ratio R_4 is defined as the equation: $R_4 = M_4 / A_4$, wherein M_4 is the total area of the test keys formed on the fourth free area A_4 ; wherein a fifth measurement ratio R_s is defined as the equation: $R_s = M_s / A_s$, wherein M_s is the total area of the test keys formed on the fifth free area A_s ; and wherein a total measurement ration R is defined as the equation $R = (M_1 + M_2 + M_3 + M_4 + M_s) / (A_1 + A_2 + A_3 + A_4 + A_s)$ (Figure 13A – 13D).

40. In re claim 35, Hara discloses wherein the first measurement ratio R_1 is less than about 10% (Figure 13A – 13D).

41. In re claim 36, Hara discloses wherein the distance D_4 is less than about 600 μm (Figures 13A – 13D).

42. In re claim 37, Hara discloses wherein the width S_1 of the first scribe line is greater than about 20 μm (Figures 13A – 13D).

43. In re claim 38, Hara discloses wherein the width S_2 of the second scribe line is greater than about 20 μm (Figures 13A – 13D).

44. In re claim 39 Hara discloses wherein the multi-layer structure is formed on a substrate selected from the group consisting of bulk Si, SOI, SiGe, GaAs and InP (Column 3, Lines 46 – 49).

45. In re claim 40, Hara discloses wherein each of said four dies comprises: a first peripheral region parallel to said first scribe line; a second peripheral region parallel to said second scribe line; a conductive ring formed between said die and said first peripheral region and said second peripheral region; and an array of apertures formed in the conductive ring and adjacent the corner area of the die (Figures 4 and 13A – 13D).

46. In re claim 41, Hara discloses wherein the low-k dielectric layer has a dielectric constant less than approximately 3.5 (Column 4, Lines 27 – 31).

47. In re claim 42, Hara discloses wherein the array of apertures comprises two rows of holes (Figures 13A – 13D).

48. In re claim 43, Hara discloses wherein said array of apertures comprises at least two slots (Figures 13A – 13D).

49. In re claim 44, Hara discloses wherein the array of apertures extends along at least one of the first peripheral region and the second peripheral region (Figures 13A – 13D).

50. In re claim 45, Hara discloses wherein each of the four dies further comprises a circuit area with a plurality of circuit elements, wherein the conductive ring is electrically connected to the circuit elements to apply one of a power source and a ground potential to the circuit elements (Figure 4).

51. In re claim 46, Hara discloses wherein the conductive ring has a width of between about 50 μm and 300 μm (Figure 11).

Application/Control Number: 10/675,892⁸⁶²
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Conclusion

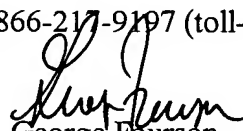
Any inquiry concerning this communication or earlier communications from the examiner should be directed to Fernando L. Toledo whose telephone number is 571-272-1867. The examiner can normally be reached on Mon-Thu 7am to 5:30pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Olik Chaudhuri can be reached on 571-272-1855. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see <http://pair-direct.uspto.gov>. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).



FToledo
23 June 2005



George Fourson
Primary Examiner
Art Unit 2823